

**TRANSMITTAL OF FORMAL DRAWINGS**Docket No.  
**FIS920030199US1**In Re Application Of: **Huagie Chen, et al.**

Serial No.

10/604,607

Filing Date

8/4/03

Confirmation No.

Examiner

Art Unit

Inventor(s)

**STRUCTURE AND METHOD OF MAKING STRAINED SEMICONDUCTOR CMOS TRANSISTORS  
HAVING LATTICE-MISMATCHED SOURCE AND DRAIN REGIONS**

Address to:

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Transmitted herewith are:

5 sheets of formal drawing(s) for this application.

☒ Each sheet of drawing indicates the identifying indicia suggested in 37 CFR Section 1.84(c).

Signature

**H. DANIEL SCHNURMANN  
AGENT  
REGISTRATION NO.: 35,791**Dated: **SEPTEMBER 23, 2003**

I certify that this document and attached formal drawings are being deposited on September 23, 2003 with the U.S. Postal Service as first class mail under 37 C.F.R. 1.8 and addressed to the Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.

Signature of Person Mailing Correspondence

**Karen Cinq-Mars**

Typed or Printed Name of Person Mailing Correspondence